

E UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Tak Kin Chu, et. al.

Serial No.: 09/853,925

Group Art Unit:

N/A M

Filed:

May 9, 2001

Examiner: Thanh Nguyên

For: ELECTORNIC DEVICES WITH DIFFUSION BARRIER AND PROCES

FOR MAKING SAME

AMENDMENT

Commissioner for Patents and Trademarks Washington, D.C. 20231

Sir:

Responsive to telephone conferences with Examiner Nguyen, the following amendments and remarks are respectfully submitted in connection with the above identified application.

In the Claims:

Amend claims 15, 16, 17, 18, 20, 22, 23, 24, 25, 26, 27 and 28 to depend on new claim 29.

15. (Amended) A process for making a semiconductor device according to claim 29, wherein the forming of the barrier film comprises the following substeps:

vapor depositing a metal halide on the cleaned heated